

10/689528

Classification: 438/382.000

Status: 30 - DOCKETED NEW CASE - READY FOR EXAMINATION

Title: PROCESS AND INSTALLATION FOR DOPING AN ETCHED PATTERN OF RESISTIVE ELEMENTS


Examiner: LEBENTRITT, MICHAEL

Inventor: GRIS, YVON

GAU: 2824

Bib Data report

**Application Title:** PROCESS AND INSTALLATION FOR DOPING AN ETCHED PATTERN OF RESISTIVE ELEMENTS

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**Examiner:** 73858 LEBENTRITT, MICHAEL (Assignment Data) **Group Art**  
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**State or Country:** FRANCE **Sheets/Drawing:** 2 **Total Claims:** 24  
**Independent Claims:** 3

▼ **Inventors:**

**Last name, First name:** **City:** **Country or State:**

GRIS, YVON TULLINS FRANCE

**Attorneys:** ALL **Attorney Docket No:** 02GR102454481

**Interference No:** **Lost Case:** No **Unmatched Petition:** No **L&R Code:** 1